

# **Japan TC Chapter Compound Semiconductor Materials Global Technical Committee**

## **Liaison Report**

**Jun. 15, 2021**

**v1**

# Meeting Information



- Last meeting
  - May 26, 2021 at Japan Spring 2021 Meetings
    - Web Conference
  
- Next meeting
  - Jan. 19, 2022 at Japan Winter 2022 Meetings
    - Web Conference

<http://www.semi.org/en/standards-events>

# Leadership

- Co-Chairs: Masayoshi Obara (Shin-Etsu Handotai Co., Ltd.)



# Organization Chart



# New TFOF



- **Silicon Carbide Substrate liaison TF**

- Charter: Discussions will be held in Japan to support and complement Silicon Carbide materials revision and new standards development activities in other regions.
- Scope: To cover the scope of the Silicon Carbide Substrate Task Force for its on existing SEMI Silicon Carbide Standards and new Standards as such become necessary.

# Ballot Review

Doc #	Document Title	TC Chapter Action
None		

**#1: Passed** ballots and line items will be submitted to the ISC Audit & Review Subcommittee for procedural review.

**#2: Failed** ballots and line items were returned to the originating task forces for re-work and re-balloting or abandoning.

# Authorized Activities

Doc #	Type	SC/TF/WG	Details
None			

# Task Force Highlights



- The Japan TC Chapter discharged four Inactive TFs in the last Japan TC Chapter Meetings.
- The Japan TC Chapter approved a New TFOF ‘ Silicon Carbide Substrate Liaison TF’. Please refer the New TFOF page.

# 5-Year Review

Designation #	Standard Title	Action By	Assigned to
None			

# Thank you!

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